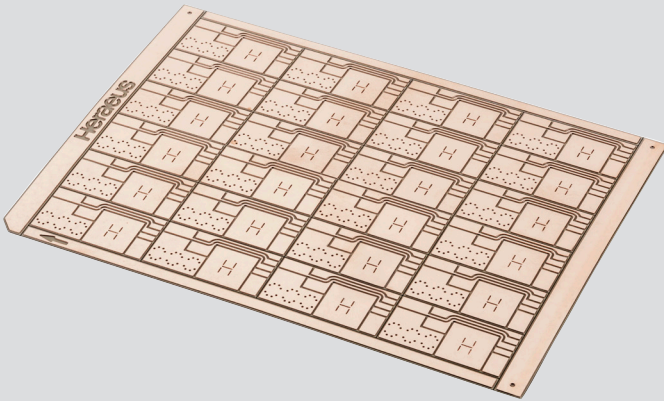


## Condura®.classic Metal Ceramic Substrates DPIS<sup>(1)</sup>



### Alumina DCB facts

- Alumina ceramic Al<sub>2</sub>O<sub>3</sub> (96 %)
  - Thicknesses<sup>(2)</sup>: 0.25 mm/0.32 mm/0.38 mm/0.63 mm
- Direct Copper Bonding Cu-OFE
  - Thicknesses<sup>(2)</sup>: 0.2 mm/0.25 mm/0.3 mm/0.4 mm
- Single unit or master card size 7 " x 5 " (usable area)
- Surface finish: bare Cu, Ni, Ni/Au (others planned)

### Key features

- Pre-qualified solutions & optimized surfaces
- Fast sample delivery target for standard material combinations
  - Europe: 5 working days
  - Worldwide: 15 working days (after drawing approval)
- Improved warpage / customization possible

### Main properties raw Al<sub>2</sub>O<sub>3</sub>

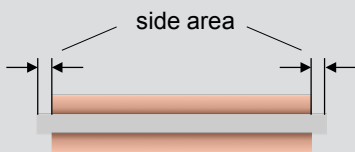
	Rating	Unit
Thermal conductivity @ 20 °C	≥ 20	W/m.K
Bending strength	> 450	N/mm <sup>2</sup>
Young's modulus	≥ 300	GPa
Coefficient of thermal expansion (Al <sub>2</sub> O <sub>3</sub> ) @ 100 °C - 600 °C	6.7 - 8.7	ppm/k

## Condura®.classic Design Rules Al<sub>2</sub>O<sub>3</sub> DPIS<sup>(1)</sup>

### Material properties raw Al<sub>2</sub>O<sub>3</sub><sup>(3)</sup>

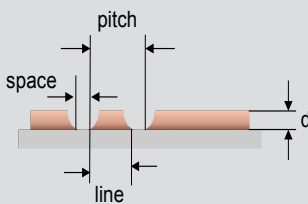
	Rating	Unit
Density	> 3.73	g/cm <sup>3</sup>
Electrical resistivity	≥ 10 <sup>13</sup>	Ohm·cm
Dielectric strength	> 15	kV/mm

### Copper free area



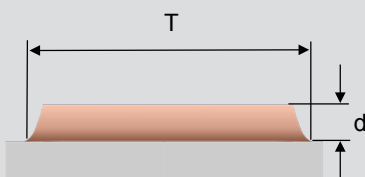
Thickness Cu [mm]	Min. side area [mm]
0.20	0.20
0.25	0.23
0.30	0.25
0.40	0.35

### Structuring



Thickness Cu [mm]	Min. space [mm]	Min. line [mm]	Min. pitch [mm]
0.20	0.40	0.40	0.80
0.25	0.45	0.45	0.90
0.30	0.50	0.50	1.00
0.40	0.60	0.60	1.20

### Etching tolerance

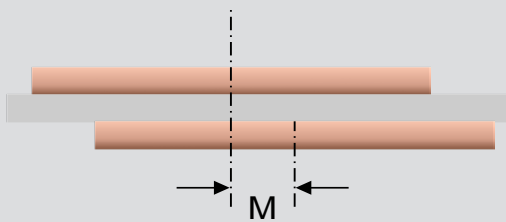


Tolerance length & width [mm]	Thickness Cu [mm]
T <sub>typ.</sub> = ± 0.15	d = 0.2
T <sub>typ.</sub> = ± 0.20	d ≤ 0.3
T <sub>typ.</sub> = ± 0.20	d ≤ 0.4

## Condura®.classic Design Rules Al<sub>2</sub>O<sub>3</sub> DPIS<sup>(1)</sup>

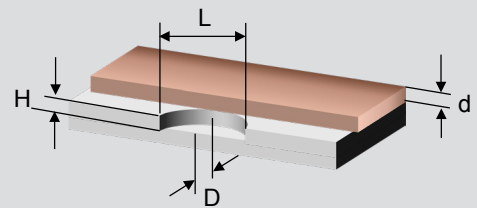
### Tolerance and chip off

#### Tolerance



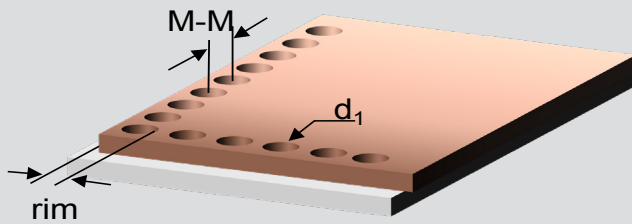
Mismatch  $M \leq 0.1$  mm  
Tolerance of total thickness = + 7 % / -10 %

#### Chip-off at ceramic edge



Length  $L \leq d$   
Depth  $D \leq \frac{1}{2}d$   
Height  $H \leq \frac{1}{2}d$

### Dimple structure



Thickness Cu [mm]	Dimple area rim [mm]	Dimple diameter d <sub>1</sub> [mm]	Dimple pitch M-M [mm]
0.20			
0.25		To be agreed	
0.30			
0.40			

### Dimensions

General dimensions	Rating (mm)
Master card	138 x 190.5
Max. usable area	127 x 178
Minimum dimension for ceramic thickness $\leq 0.63$ mm	10 x 10 (smaller on request)

Tolerances of single parts	Rating (mm)
Ceramic thickness $\leq 0.63$ mm	+ 200 $\mu$ m - 50 $\mu$ m

Warpage behavior depends on specific layout, single part size and material combination and can only be specified after initial sample preparation.

### Surface plating

Plating Method	Thickness ( $\mu$ m)
Electroless Ni	3 - 7 (9% $\pm$ 2% P)
	Ni 3 - 7 (9% $\pm$ 2% P)
Electroless NiAu	Au Class 1: 0.01 - 0.05
	Au Class 2: 0.03 - 0.13

## Condura®.classic Design Rules Al<sub>2</sub>O<sub>3</sub> DPIS<sup>(1)</sup>

### Metal & hole properties

Roughness	Minimum hole diameter	
Rmax = 50 µm	d <sub>hole</sub> = 1 mm	
Ra ≤ 3.5 µm		
Rz ≤ 24 µm		
Electrical conductivity raw copper	Thickness Cu	Copper peeling Strength
G <sub>Cu</sub> = 58 · 10 <sup>6</sup> S/m	0.30mm	> 4 N/mm

### HET Academy R&D Application Center

Besides offering Assembly Materials, Bonding Wires and Metal Ceramic Substrates, Heraeus Electronics provides matching material solutions and R&D oriented partnerships to create individual solutions.

### Application conditions and assembly optimization

Thermal shock test cycles	Customized surface for assembly process
-55 °C up to +150 °C	Optimization of surface and assembly process parameters available or in development cooperation for:
Under Investigation	<ul style="list-style-type: none"> <li>■ Sintering</li> <li>■ Solder wetting</li> <li>■ Heavy wire bondability</li> </ul>

03.2019, Layout: CF

#### Heraeus Electronics offers:

- Reliable IATF 16949 certified supply of:
  - ✓ Condura®.prime AMB-Si<sub>3</sub>N<sub>4</sub> (active metal brazed Si<sub>3</sub>N<sub>4</sub>)
  - ✓ Condura®.extra DCB-ZTA (zirconia-toughened alumina)
  - ✓ Condura®.classic DCB-Al<sub>2</sub>O<sub>3</sub> (direct copper bonded Al<sub>2</sub>O<sub>3</sub>)
- Condura®+ for example:
  - ✓ Engineering Services (Simulation, Prototype Design & Assembly, Testing and Qualification, Material Analysis)
  - ✓ Pre-applied sinter / solder
- To be your competent **one-stop materials solutions partner!**

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